

Judul:

Plasma power effect on the surfaces of a quartz crystal during etching using tetrafluoroethane gas

Pengarang/Penulis:

Masrurroh, author

Subjek:

Microbalances--Congresses

Nomor Panggil:

UI-IJTECH 8:8 (2017)

Penerbitan:

Faculty of Engineering, Universitas Indonesia

Link Terkait:

- [Deskripsi Bibliografi](#)
- [Abstrak](#)
- [Dokumen Yang Mirip](#)
- [Universitas Indonesia Library](#)